

Parallel electric field amplification by phase mixing of Alfvén waves

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ABSTRACT

Context. Several numerical studies have identified phase mixing of low-frequency Alfvén waves as a means of parallel electric field amplification and acceleration of electrons in a collisionless plasma.

Aims. Theoretical explanations are given of how phase mixing amplifies the parallel electric field and, as a consequence, also leads to enhanced collisionless damping of the wave by energy transfer to the electrons.

Methods. Our results are based on the properties of the Alfvén waves in a warm plasma. These results are obtained within the framework of drift-kinetic theory.

Results. Phase mixing in a collisionless low- β plasma proceeds in a manner very similar to the resistive case, except that electron Landau damping is the primary energy dissipation channel. The time and length scales involved are evaluated. We also focus on the evolution of the parallel electric field and calculate its maximum value in the course of its amplification

Key words. magnetohydrodynamics (MHD) – waves – Sun: corona

1. Introduction

At finite wave numbers in the direction perpendicular to the ambient magnetic field, Alfvén waves produce a compression of the plasma that results in the creation of a parallel electric field via the thermo-electric effect, i.e. from electron pressure fluctuations along the magnetic field lines (see discussion below and, e.g., Hollweg 1999). This situation occurs in a plasma with a pressure parameter β that is greater than m_e/m_i . In contrast, when the pressure parameter is below m_e/m_i , the parallel electric field of the Alfvén wave is mainly balanced by electron inertia. These warm and cold plasma regimes of the dispersive Alfvén wave are dubbed kinetic and inertial, respectively. This parallel electric field, whose magnitude increases with k_\perp , leads to wave-particle interactions, hence to Landau damping of the Alfvén wave.

The importance of this parallel electric field was pointed out some time ago by Hasegawa & Chen (1976). Indeed, they consider resonant absorption (Hasegawa & Chen 1974) in a warm plasma and argue that it is a manifestation of mode conversion from the MHD Alfvén wave (AW) to the kinetic Alfvén wave (KAW). As a result, the physical mechanism of the heating depends on the collisionless absorption of the KAW. Although the original motivation was to explain electron heating in laboratory fusion plasmas, this electric field was also proposed as a mechanism that can accelerate electrons in space plasmas (Hasegawa 1976; Hasegawa & Mima 1978; Hasegawa 1985; Goertz & Boswell 1979) and that helps for understanding solar coronal heating (Ionson 1978).

Heyvaerts & Priest (1983) also introduced the idea of phase mixing to improve the efficiency of AW dissipation. Their theory is based on visco-resistive magnetohydrodynamics (MHD). Since then, MHD phase mixing has attracted a significant amount of attention in the context of heating open magnetic structures in the solar corona (Parker 1991; Nakariakov et al. 1997; Botha et al. 2000; De Moortel et al. 2000; Hood et al. 2002). Popular excitation mechanisms for coronal AWs in open magnetic structures are photospheric motions for the

low-frequency and chromospheric reconnection events for the high-frequency range of the spectrum.

Phase mixing can be understood as the refraction of the wave while it propagates along a magnetic field with transverse variation in the Alfvén velocity, i.e. the progressive increase of its k_\perp . This is a special occurrence of an anisotropic conservative energy cascade, a phenomenon generally attributed to non-linear interactions between wave packets. For more details, see the discussion in (Bian & Tsiklauri 2008). Therefore, it is not surprising that phase mixing produces amplification of the parallel electric field that accompanies the Alfvén wave in a collisionless plasma, although this cannot be understood within the framework of ideal MHD theory, which assumes $E_\parallel = 0$.

Previous numerical studies of phase mixing in a collisionless plasma have identified its involvement in the generation of a parallel electric field and acceleration of electrons (Tsiklauri et al. 2005a,b; Tsiklauri & Haruki 2008); see also Genot et al. (1999, 2004) in the context of the magnetosphere. As stated above, the same features have been established already some time ago by Hasegawa and Chen for resonant absorption. Here, we provide a detailed discussion of the role played by phase mixing in both parallel electric field amplification and enhanced electron Landau damping of AWs in a collisionless plasma.

The calculations are based on the drift-kinetic theory presented in Sect. 2, which is valid in the limit of low-frequency fluctuations with $\omega \ll \omega_{ci}$, ω_{ci} is the ion cyclotron frequency. Phase mixing and enhanced electron Landau damping of AWs in a collisionless low- β plasma are considered in Sect. 3. Parallel electric field amplification is studied in Sect. 4. Conclusions and discussions are provided in Sect. 5.

2. Kinetic properties of the Alfvén wave in a warm collisionless plasma

Our starting point is the linearized drift-kinetic equation describing the magnetic field aligned dynamics of the electrons:

$$\partial_t f_1 + v_\parallel \nabla_\parallel f_1 - \frac{e}{m_e} E_\parallel \partial_{v_\parallel} f_0 = 0. \quad (1)$$

Here, the electron distribution is written as the sum of a background and a small perturbation; i.e., $f(x, y, z, v_{\parallel}, t) = f_0(v_{\parallel}) + f_1(x, y, z, v_{\parallel}, t)$. We assume the existence of a background magnetic field $\mathbf{B}_0 = B_0 \mathbf{z}$ directed along z . The parallel component of any field F is written as F_{\parallel} , and the perpendicular component is F_{\perp} . This notation also holds for the differential operator ∇ , hence the notation k_{\perp} and k_{\parallel} for the perpendicular and the parallel wave number, respectively.

The drift-kinetic equation is supplemented by Maxwell's equations. Faraday's law is

$$E_{\parallel} = -\nabla_{\parallel} \phi - \frac{1}{c} \frac{\partial A_{\parallel}}{\partial t}, \quad (2)$$

where ϕ is the electric potential, A_{\parallel} the parallel component of the vector potential. The parallel component of Ampere's law reads

$$\nabla_{\perp}^2 A_{\parallel} = \frac{4\pi e}{c} \int v_{\parallel} f_1 dv_{\parallel}. \quad (3)$$

The above system is closed by the quasi-neutrality condition, which in the limit $k_{\perp} \rho_i \ll 1$, reads as

$$n_0 \rho_i^2 \nabla_{\perp}^2 \frac{e\phi}{T_{0i}} = \int f_1 dv_{\parallel}, \quad (4)$$

where ρ_i is the thermal ion Larmor radius at the temperature T_{0i} , and n_0 the background density. We set the Boltzmann constant to unity, which means that the temperature has the unit of energy. While this so-called gyrokinetic Poisson equation (Eq. (4)) includes the effect associated with the ion dynamics, i.e. their perpendicular polarization drift, the electron response along the perturbed field lines is described by the drift-kinetic equation (Eq. (1)).

We assume a small deviation f_1 from an equilibrium Maxwellian distribution f_0 :

$$f_0(v_{\parallel}) = \frac{n_0}{\sqrt{\pi} v_{te}} e^{-v_{\parallel}^2/v_{te}^2}, \quad (5)$$

with v_{te} the electron thermal speed. The above closed set of equations is a self-consistent description of the linear plasma dynamics and is a simple form of gyrokinetics. This description of the plasma dynamics is based on an averaging of the kinetic and Maxwell equations over the gyromotion of the particles. This procedure is valid in the limit of frequencies that are small compared to the ion cyclotron frequency and within the limit of a small Larmor radius. Moreover, it is assumed that fluctuations are small and anisotropic: $k_{\parallel}/k_{\perp} \sim \delta B/B_0 \ll 1$. As for reduced MHD, there is pressure balance in the direction perpendicular to the background magnetic field, such that the fast mode is ordered out. Finally, because the gyroaverage procedure eliminates the cyclotron resonance, the only type of wave-particle interaction that remains possible is through the Landau resonance between the particles and the parallel electric force. We refer to the recent work by [Schekochihin et al. \(2009\)](#) for a review on astrophysical gyrokinetics.

The electron density perturbation is defined as $n_e = \int f_1 dv_{\parallel}$ and the parallel current perturbation as $J_{\parallel} = -e \int v_{\parallel} f_1 dv_{\parallel} = -en_0 u_{\parallel e}$, where $u_{\parallel e}$ is the electron parallel velocity, and the electron pressure perturbation is defined as $P_e = m_e \int v_{\parallel}^2 f_1 dv_{\parallel}$. Ampere's law and Poisson law can thus be written, respectively, as $\nabla_{\perp}^2 A_{\parallel} = -(4/\pi c) J_{\parallel}$ and $\rho_i^2 \nabla_{\perp}^2 e\phi/T_{0i} = n_e/n_0$. On one hand, taking the zeroth order moment of the electron kinetic equation provides the electron continuity equation:

$$\frac{\partial n_e}{\partial t} + n_0 i k_{\parallel} u_{\parallel e} = 0. \quad (6)$$

On the other hand, the first moment provides the parallel electron momentum equation:

$$n_0 m_e \frac{\partial u_{\parallel e}}{\partial t} = -i k_{\parallel} P_e - n_0 e E_{\parallel}. \quad (7)$$

It is usual to refer to the last equation as Ohm's law, and $P_e = n_e T_{0e}$ for an isothermal plasma. Therefore, there are two possible sources of parallel electric field associated with the electron dynamics: inertia and pressure (or density) variations along the field lines. The continuity equation combined with Poisson law yields a vorticity equation:

$$\frac{\partial}{\partial t} \rho_i^2 \nabla_{\perp}^2 \frac{e\phi}{T_{0i}} + \frac{c}{4\pi e n_0} i k_{\parallel} \nabla_{\perp}^2 A_{\parallel} = 0. \quad (8)$$

Neglecting first the effects of electron inertia and electron pressure gradient in Ohm's law yields the MHD Ohm's law $E_{\parallel} = 0$, i.e.,

$$\frac{1}{c} \frac{\partial A_{\parallel}}{\partial t} = -i k_{\parallel} \phi. \quad (9)$$

Introducing the stream and flux function for the velocity $\mathbf{u}_{\perp} = \mathbf{z} \times \nabla_{\perp} \varphi$, and the magnetic field $\mathbf{B}_{\perp} / \sqrt{4\pi n_0 m_i} = \mathbf{z} \times \nabla_{\perp} \psi$, defined as $\varphi = (c/B_0)\phi$ and $\psi = -A_{\parallel} / \sqrt{4\pi n_0 m_i}$, gives

$$\frac{\partial}{\partial t} \nabla_{\perp}^2 \varphi = v_A i k_{\parallel} \nabla_{\perp} \psi, \quad (10)$$

$$\frac{\partial \psi}{\partial t} = v_A i k_{\parallel} \varphi, \quad (11)$$

with $v_A = B_0 / \sqrt{4\pi n_0 m_i}$ the Alfvén velocity. These two equations are the standard linearized reduced-MHD equations describing shear-Alfvén waves with frequency:

$$\omega = \pm v_A k_{\parallel}. \quad (12)$$

When the parallel electric field is produced by a density fluctuation in Ohm's law, we have $E_{\parallel} = -i k_{\parallel} T_{0e} (n_e/n_0)$. Using the Poisson equation, $E_{\parallel} = -i k_{\parallel} \rho_s^2 \nabla_{\perp}^2 \phi$, which also reveals the vortical nature of the parallel electric field. The parameter $\rho_s = c_s/\omega_{ci} = \sqrt{T_{0e}/T_{0i}} \rho_i$ is the ion gyroradius at the electron temperature. By including this parallel electric field in Ohm's law, an extension of the previous reduced-MHD system now takes the form

$$\frac{\partial}{\partial t} \nabla_{\perp}^2 \varphi = v_A i k_{\parallel} \nabla_{\perp} \psi, \quad (13)$$

$$\frac{\partial \psi}{\partial t} = v_A i k_{\parallel} (\varphi - \rho_s^2 \nabla_{\perp}^2 \varphi), \quad (14)$$

which describes the dynamics of kinetic Alfvén waves with frequency

$$\omega = \pm v_A k_{\parallel} \sqrt{1 + \rho_s^2 k_{\perp}^2}. \quad (15)$$

It is worth noticing that Eqs. (13), (14) can also be obtained directly from two-fluid MHD theory by retaining the Hall and electron pressure effects in Ohm's law ([Bian & Tsiklauri 2009](#)). Using the above results, it is easily seen that, for kinetic Alfvén waves, the magnitude of the parallel electric field is related to B_{\perp} by

$$E_{\parallel} = \frac{v_A}{c} k_{\parallel} \frac{k_{\perp} \rho_s^2}{\sqrt{1 + k_{\perp}^2 \rho_s^2}} B_{\perp}. \quad (16)$$

The above fluid derivation of the Alfvén wave frequency gives the same result as its kinetic counterpart, however the latter, which is presented below, is more complete in the sense that it also provides the imaginary part associated with Landau damping. The electron kinetic equation can be solved for the perturbed distribution function f_1 , i.e.,

$$f_1 = i \frac{e}{m_e} E_{\parallel} \frac{2n_0}{\sqrt{\pi} k_{\parallel} v_{te}^3} \frac{v_{\parallel}/v_{te}}{v_{\parallel}/v_{te} - \omega/k_{\parallel} v_{te}} e^{-v_{\parallel}^2/v_{te}^2}. \quad (17)$$

Some notations are introduced: $x = v_{\parallel}/v_{te}$, $\alpha = \omega/k_{\parallel} v_{te}$ and

$$Z_n(\alpha) = \frac{1}{\sqrt{\pi}} \int \frac{x^n}{x - \alpha} e^{-x^2} dx, \quad (18)$$

with $Z_0(\alpha)$ the standard plasma dispersion function. We also summarize some properties of the functions Z_n : $Z_1 = 1 + \alpha Z_0$, $Z_2 = \alpha Z_1$. Moreover, in the limit $\alpha \ll 1$

$$Z_0(\alpha) \sim -2\alpha + i\sqrt{\pi}(1 - \alpha^2). \quad (19)$$

Using the above properties, it follows that the density and current perturbations are related to the parallel electric field through

$$\int f_1 dv_{\parallel} = \frac{2ien_0}{m_e k_{\parallel} v_{te}^2} [1 + \alpha Z_0(\alpha)] E_{\parallel}, \quad (20)$$

for the density, and

$$\int f_1 v_{\parallel} dv_{\parallel} = \frac{2ien_0 \omega}{m_e k_{\parallel}^2 v_{te}^2} [1 + \alpha Z_0(\alpha)] E_{\parallel}. \quad (21)$$

As a result, the relation between the parallel current and the parallel electric field is

$$J_{\parallel} = \frac{-i\omega}{4\pi k_{\parallel}^2 \lambda_{De}^2} [1 + \alpha Z_0(\alpha)] E_{\parallel}. \quad (22)$$

It is convenient to define a collisionless plasma conductivity σ as

$$J_{\parallel} = \sigma E_{\parallel}. \quad (23)$$

Its imaginary part results in the dispersion of the Alfvén wave and its real part yields the collisionless dissipation. In the limit $\alpha \equiv \omega/k_{\parallel} v_{te} \ll 1$, the real part is

$$\sigma_r \simeq \frac{e^2 m_e^{1/2} n_0 \omega^2}{k_{\parallel}^3 T_{0e}^{3/2}}. \quad (24)$$

This also gives the energy per unit time transferred to the electrons through the relation

$$Q = \text{Re}(J_{\parallel} E_{\parallel}^*); \quad (25)$$

i.e.,

$$Q = \frac{\sqrt{\pi} \omega^2}{k_{\parallel}^3 \lambda_{De}^2 v_{te}} U_{E_{\parallel}}, \quad (26)$$

with λ_{De} the electron Debye length and $U_{E_{\parallel}} = |E_{\parallel}^2| / 8\pi$ the energy density of the parallel component of the electric field. It is, in fact, a standard result that the asymptotic $\omega t \gg 1$ averaged power transferred to electrons, $Q = \int v_{\parallel} \langle -e E_{\parallel} f_1 \rangle dv_{\parallel}$, due to the presence of an harmonic electric field fluctuation $E_{\parallel} = \cos(k_{\parallel} z - \omega t)$, is

$$Q = -\pi \frac{e^2 E_{\parallel}^2}{2m_e k_{\parallel}} \left[v_{\parallel} \frac{\partial f_0}{\partial v_{\parallel}} \right]_{v_{\parallel}=\omega/k_{\parallel}}. \quad (27)$$

It can be verified easily from Eq. (1) and for a Maxwellian distribution that this last result is equivalent to Eq. (26). Using the relation between E_{\parallel} and B_{\perp} , Q can finally be expressed in term of the magnetic energy, $U_B = |B_{\perp}^2| / 8\pi$,

$$Q = \frac{\sqrt{\pi} \omega^2}{k_{\parallel} v_{te}} \frac{k_{\perp}^2 \rho_s^2}{1 + k_{\perp}^2 \rho_s^2} U_B. \quad (28)$$

The coefficient of proportionality between Q and U_B , which has the dimension of the inverse of a time, is nothing else than the Landau damping rate.

The Landau damping rate is now obtained directly from the complex dispersion relation. The kinetic dispersion relation is obtained from: $\nabla_{\perp}^2 A_{\parallel} = i\omega / (k_{\parallel}^2 \lambda_{De}^2 c) [1 + \alpha Z_0(\alpha)] E_{\parallel}$, $\rho_s^2 \nabla_{\perp}^2 \phi = i/k_{\parallel} [1 + \alpha Z_0(\alpha)] E_{\parallel}$ and $E_{\parallel} = -ik_{\parallel} \phi + i\omega A_{\parallel} / c$. It is

$$\rho_s^2 k_{\perp}^2 + \left(1 - \frac{\omega^2}{k_{\parallel}^2 v_A^2} \right) [1 + \alpha Z_0(\alpha)] = 0. \quad (29)$$

This is the general complex dispersion relation for the dispersive Alfvén wave. In the limit $\alpha \ll 1$, it reads as

$$\omega^2 = k_{\parallel}^2 v_A^2 [1 + k_{\perp}^2 \rho_s^2 (1 - i\sqrt{\pi}\alpha)]. \quad (30)$$

Its real part corresponds to the frequency of the kinetic Alfvén wave, which was also derived from fluid theory above. Its imaginary part, which corresponds to the Landau damping rate (see also Eq. (28)), reads as

$$\gamma(\mathbf{k}) = \frac{\sqrt{\pi}}{2} \frac{v_A^2}{v_{te}} k_{\parallel} k_{\perp}^2 \rho_s^2. \quad (31)$$

Most calculations above were finalized in the limit $\alpha \ll 1$. In the opposite limit of $\alpha \gg 1$, one obtains the frequency and damping rate of the inertial Alfvén wave, which has its parallel electric field balanced by the electron inertia in Ohm's law. For frequency $\omega \sim k_{\parallel} v_A$, $\alpha \sim v_A / v_{te}$. It means that the kinetic Alfvén wave regime corresponds to $v_A / v_{te} \ll 1$ and the inertial Alfvén wave regime corresponds to $v_A / v_{te} \gg 1$. In the following we continue to focus on the warm plasma regime corresponding to $1 \gg \beta \gg m_e / m_i$, where β is the pressure parameter. Landau damping of the inertial Alfvén wave and its effect on phase mixing can be treated similarly.

3. Phase mixing

Phase mixing of a shear Alfvén wave packet can be considered in the framework of an eikonal description:

$$\frac{d\mathbf{x}}{dt} = \nabla_{\mathbf{k}} \omega, \quad (32)$$

$$\frac{d\mathbf{k}}{dt} = -\nabla_{\mathbf{x}} \omega, \quad (33)$$

with $\omega = \pm k_{\parallel} v_A$. These are the characteristics of the wave-kinetic equation

$$\frac{\partial e_{\pm}}{\partial t} + \nabla_{\mathbf{k}} \omega \nabla_{\mathbf{x}} e_{\pm} - \nabla_{\mathbf{x}} \omega \nabla_{\mathbf{k}} e_{\pm} = -\gamma(\mathbf{k}) e_{\pm}. \quad (34)$$

In the latter equation e_{\pm} are the amplitudes of the wave packets corresponding to $\omega = \pm k_{\parallel} v_A$, and $\gamma(\mathbf{k})$ is a wave number dependent damping rate. Following the trajectory of a wave packet in phase space (\mathbf{x}, \mathbf{k}) , its amplitude evolves according to

$$\frac{de_{\pm}}{dt} = -\gamma(\mathbf{k}) e_{\pm}. \quad (35)$$

This equation is integrated to give

$$e_{\pm}(t) = e_{\pm}(0) \exp\left(-\int \gamma(\mathbf{k}) dt\right). \quad (36)$$

The principle of phase mixing is simple: for any damping rate γ that is an increasing function of k , any mechanism producing an increase in k as a function of time also results in a smaller damping time scale. This is precisely the situation which occurs when the Alfvén wave packet propagates along field lines with a transverse variation of the Alfvén speed: the wave packet is sheared. In this case, say $\mathbf{v}_A(x) = -v'_A x \mathbf{z}$, \mathbf{z} is the unit vector in the parallel direction and x the transverse coordinate, then

$$\frac{dk_{\perp}}{dt} = k_{\parallel} v'_A, \quad (37)$$

with by definition $v'_A = v_A/L_{\perp}$, L_{\perp} being the characteristic length of the transverse inhomogeneity and $k_{\parallel} = k_{\parallel}(t=0)$. This means that k_{\perp} increases linearly with time due to differential advection of the wave packets along the field lines, i.e.,

$$k_{\perp}(t) = k_{\parallel} v'_A t, \quad (38)$$

where we have taken $k_{\perp}(t=0) = 0$ without loss of generality.

For resistive MHD, Ohm's law reads as $E_{\parallel} = \eta J_{\parallel}$ and the following results are well known. The damping rate is $\gamma(\mathbf{k}) = \eta c(k_{\perp}^2 + k_{\parallel}^2)/4\pi = D_m(k_{\perp}^2 + k_{\parallel}^2)$. This is the Fourier transform of the operator responsible for magnetic diffusion in the induction equation. Hence,

$$e_{\pm}(t) = e_{\pm}(0) \exp\left[-D_m k_{\parallel}^2 \int (1 + v_A'^2 t^2) dt\right], \quad (39)$$

which in the limit $t \gg v_A'^{-1}$ yields

$$e_{\pm}(t) \sim e_{\pm}(0) \exp\left(-\frac{D_m v_A'^2 k_{\parallel}^2}{3} t^3\right). \quad (40)$$

Since, $z = v_A t$, we also have

$$e_{\pm}(z) \sim e_{\pm}(0) \exp\left(-\frac{D_m v_A'^2 \omega^2}{3 v_A^5} z^3\right), \quad (41)$$

for an Alfvén wave excited at $z = 0$ with frequency ω . In a collisionless plasma, when the dissipation is provided by electron Landau damping, with damping rate $\gamma(\mathbf{k}) = \sqrt{\pi} v_A^2 k_{\parallel} k_{\perp}^2 / 2v_{te}$, the equivalent expressions are

$$e_{\pm}(t) = e_{\pm}(0) \exp\left(-\frac{\sqrt{\pi}}{6} \frac{v_A^2 v_A'^2}{v_{te}} \rho_s^2 k_{\parallel}^3 t^3\right) \quad (42)$$

and

$$e_{\pm}(z) = e_{\pm}(0) \exp\left(-\frac{\sqrt{\pi}}{6} \frac{v_A^2}{v_A^4 v_{te}} \rho_s^2 \omega^3 z^3\right), \quad (43)$$

for an Alfvén wave excited at $z = 0$ with frequency ω . The collisionless phase mixing time scale is thus

$$\tau_{\text{pm}} \sim \frac{v_{te}^{1/3} L_{\perp}^{2/3}}{v_A^{4/3} \rho_s^{2/3} k_{\parallel}}, \quad (44)$$

and the phase mixing length scale is

$$l_{\text{pm}} \sim \frac{v_A^{2/3} v_{te}^{1/3} L_{\perp}^{2/3}}{\rho_s^{2/3} \omega}. \quad (45)$$

The scaling of the phase mixing length scale with the frequency ω in the spatial problem is different from that of resistive MHD phase mixing since the collisionless conductivity associated with electron Landau damping depends on ω , contrary to Spitzer conductivity. However, the dependence with time or distance of the decay law, like $\exp(-\alpha_1 t^3)$ or $\exp(-\alpha_2 z^3)$ is similar to resistive MHD phase mixing. The physical reason is obviously the common scaling of the damping rate $\gamma(\mathbf{k})$ with k_{\perp} in the collisional and collisionless cases.

The effect of electron Landau damping on phase mixing was first considered by [Voitenko & Goossens \(2000a\)](#). They derived a relation identical to Eq. (45) (see Eqs. (30) and (11) in [Voitenko & Goossens 2000a](#)). Moreover, results of the particles-in-cell (PIC) simulations carried by [Tsiklauri & Haruki \(2008\)](#) have produced $l_{\text{pm}} \propto \omega^{-\zeta}$ with $\zeta \simeq 1.10$, for the dependence of the phase mixing length scale l_{pm} with frequency ω . They also report that the parallel electric field associated with the Alfvén wave is primarily balanced by the electron pressure gradient in their simulations. They attribute the scaling of l_{pm} with ω to the effect of an anomalous resistivity. Here, we emphasize that the PIC simulation results can be clearly interpreted as the standard effect of electron Landau damping of the KAW by resonant interaction with electrons since it gives $l_{\text{pm}} \propto \omega^{-\zeta}$ with $\zeta = 1$. As a rule, the Landau damping rate is an increasing function of frequency and, for kinetic Alfvén waves, we have $\gamma_L(k_{\perp}, \omega) \sim k_{\perp}^2 \rho_s^2 (v_A/v_{te}) \omega$. In contrast, the resistive damping rate is independent of frequency and is rewritten as $\gamma_r(k_{\perp}) \sim \mu_e d_e^2 k_{\perp}^2$, where μ_e is the electron collisional frequency and $d_e = c/\omega_{pe}$ the electron skin depth. Therefore, it is clear that Landau damping is the dominant damping mechanism only for high-frequency Alfvén waves, where $\omega \gg \mu_e \beta_e^{-3/2}$, $\beta_e = v_{te}^2/v_A^2$ is the electron pressure parameter. For typical coronal holes conditions, $v_A/v_{te} \sim 1/2$ and $\mu_e \sim 4 \text{ s}^{-1}$, Landau damping dominates resistivity for frequencies higher than $\sim 1 \text{ s}^{-1}$, and such high-frequency Alfvén waves can propagate a distance $l \sim 2 \times 10^5 (\text{km}^{1/3} \text{ s}^{-1}) \omega^{-1} L_{\perp}^{2/3}$.

4. Parallel electric field generation

For an Alfvén wave created by a source through perturbation of the background magnetic field, a parallel electric field is produced, provided k_{\perp} is finite, which is given by Eq. (16):

$$E_{\parallel} = \frac{v_A}{c} k_{\parallel} \frac{k_{\perp} \rho_s^2}{\sqrt{1 + k_{\perp}^2 \rho_s^2}} B_{\perp}. \quad (46)$$

It is this parallel electric field that is responsible for the Landau damping of the wave (see above). For a given k_{\parallel} and δB_{\perp} , this electric field is amplified provided that the k_{\perp} associated with the wave field is also amplified. The reason is that E_{\parallel} is a monotonic increasing function of k_{\perp} . However, $E_{\parallel}(k_{\perp})$ also reaches a plateau for $k_{\perp} \rho_s \sim 1$, which is the boundary between the MHD and the dispersive regime. Indeed,

$$E_{\parallel} = \frac{v_A}{c} k_{\parallel} k_{\perp} \rho_s^2 B_{\perp} \quad (47)$$

for $k_{\perp} \rho_s \ll 1$ and E_{\parallel} reaches its maximum, of the order of

$$E_{\parallel} = \frac{v_A}{c} k_{\parallel} \rho_s B_{\perp} \quad (48)$$

when $k_{\perp} \rho_s \sim 1$ or larger. Therefore, significant amplification of this parallel electric field can only occur in the range of wave numbers where the wave is non-dispersive; i.e., it behaves as a shear-Alfvén wave with frequency $\omega \simeq \pm k_{\parallel} v_A$.

From the results of the previous section we obtain the dependence with time of the parallel electric field strength during the phase mixing process:

$$\tilde{E}_{\parallel}(t) = v'_A k_{\parallel}^2 \rho_s^2 t \exp\left(-\frac{\sqrt{\pi}}{6} \frac{v'_A v'_A}{v_{te}} \rho_s^2 k_{\parallel}^3 t^3\right), \quad (49)$$

where a normalized electric field $\tilde{E}_{\parallel} = E_{\parallel}/(B_{\perp}(0)v_A/c)$ has been defined. The variation with time $\tilde{E}(t)$ takes the form $\beta_1 t \exp(-\alpha_1 t^3)$, with a growth phase followed by a decay phase typical of the alternating field aligned current during phase mixing. Since $z = v_A t$, then

$$\tilde{E}_{\parallel}(z) = \frac{v'_A \omega^2 \rho_s^2 z}{v_A^3} \exp\left(-\frac{\sqrt{\pi}}{6} \frac{v'_A}{v_A v_{te}} \rho_s^2 \omega^3 z^3\right), \quad (50)$$

which has the form $\beta_2 z \exp(-\alpha_2 z^3)$, for an Alfvén wave excited at $z = 0$ with frequency ω . The above defined phase mixing time/length scales are precisely those scales associated with the amplification of the parallel electric field; i.e., the time/length scales for the parallel electric field to reach its maximum value given by

$$\tilde{E} \sim \frac{\omega v_{te}^{1/3} \rho_s^{4/3}}{v_A^{4/3} L^{1/3}} \quad (51)$$

with $\omega \simeq k_{\parallel} v_A$.

5. Conclusions

Previous PIC simulations of collisionless phase mixing of Alfvén waves (Tsiklauri et al. 2005a,b; Tsiklauri & Haruki 2008) have identified its relation to the generation of a parallel electric field and acceleration of electrons. The importance of this parallel electric field has been first pointed out by Hasegawa and Chen in the context of resonant absorption. They also show that the dominant energy dissipation of the Alfvén wave, in a collisionless low- β plasma, involves energy transfer to the electrons (Hasegawa & Chen 1976). The role of electron Landau damping in collisionless phase mixing has also been considered by Voitenko & Goossens (2000a,b)

Focusing on the kinetic regime of the dispersive Alfvén wave, when $v_A/v_{te} \ll 1$, we provided a detailed discussion of the role played by phase mixing in both parallel electric field amplification and enhanced electron Landau damping of the wave.

Qualitatively, the physics of collisionless phase mixing can be summarized as follows. A parallel electric field accompanies the propagation of Alfvén waves with finite k_{\perp} . The magnitude

of this electric field is an increasing function of k_{\perp} that saturates in the dispersive range when $k_{\perp} \rho_s \sim 1$ or larger. Therefore, any mechanism that produces an increase in k_{\perp} also leads to the amplification of the parallel electric field associated with the Alfvén wave. Phase mixing is such a mechanism, independently of the energy dissipation channel. Phase mixing is a special occurrence of energy-conserving cascade (Bian & Tsiklauri 2008). Such a cascade, predominantly involving perpendicular wave numbers, can also be produced by non-linear interactions (i.e. turbulence), leading to parallel electric field amplification (Bian & Kontar 2010; Bian et al. 2010). Existence of this parallel electric field and the dependence of its magnitude with k_{\perp} yield a Landau damping rate, which scales like k_{\perp}^2 , just as visco-resistive damping. This can be demonstrated very simply in the framework of drift-kinetic theory. Therefore, in a collisionless plasma, phase mixing leads to enhanced electron Landau damping of the Alfvén wave in a manner that is very similar to the well-studied case of enhanced visco-resistive damping. As a consequence, once the wave has damped in a collisionless low- β plasma, its energy has been transferred to the electrons. The time and length scales involved in the damping process were evaluated for small amplitude perturbations. Moreover, we studied the evolution of the magnitude of the parallel electric field in the course of its amplification and calculated its maximum value.

We argued that the scaling of the phase mixing length scale with frequency, $l_{pm} \propto \omega^{-\zeta}$ and $\zeta \simeq 1$, reported by (Tsiklauri & Haruki 2008) has a simple interpretation in terms of electron Landau damping. PIC simulations of collisionless phase mixing are valuable tools because they can provide direct information on the modification of the electron distribution function involved in the acceleration process, see (Tsiklauri et al. 2005a,b), a feature which the present kind of preliminary analysis is not capable of.

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